

US011108396B2

(12) **United States Patent**
Sanchez

(10) **Patent No.:** **US 11,108,396 B2**
(45) **Date of Patent:** **Aug. 31, 2021**

(54) **MULTIVOLTAGE HIGH VOLTAGE IO IN LOW VOLTAGE TECHNOLOGY**
(71) Applicant: **NXP USA, Inc.**, Austin, TX (US)
(72) Inventor: **Hector Sanchez**, Austin, TX (US)
(73) Assignee: **NXP USA, Inc.**, Austin, TX (US)
(*) Notice: Subject to any disclaimer, the term of this patent is extended or adjusted under 35 U.S.C. 154(b) by 0 days.

6,429,716	B1 *	8/2002	Drapkin	H03K 19/00315	323/313
6,777,755	B2	8/2004	Humphrey et al.		
7,428,719	B2	9/2008	Jaska et al.		
8,098,073	B2	7/2012	Butt et al.		
8,415,663	B2	4/2013	Ping et al.		
8,606,193	B2	12/2013	Ko et al.		
8,904,248	B2	12/2014	Park et al.		
9,344,088	B1	5/2016	Sanchez		
9,356,577	B2	5/2016	Sanchez et al.		
9,503,090	B2	11/2016	Fifield		
10,114,074	B2	10/2018	Loke et al.		
2003/0231044	A1	12/2003	Lundberg		
2004/0238962	A1	12/2004	Jung et al.		
2006/0091907	A1 *	5/2006	Khan	H03K 17/102	326/81
2007/0104111	A1	5/2007	Kakizawa		
2007/0247190	A1	10/2007	Chen		
2014/0210014	A1	7/2014	Ma et al.		
2015/0294970	A1	10/2015	Jakushokas et al.		
2016/0105180	A1	4/2016	Kerr et al.		

(21) Appl. No.: **16/779,532**

(22) Filed: **Jan. 31, 2020**

(65) **Prior Publication Data**

US 2021/0242871 A1 Aug. 5, 2021

(51) **Int. Cl.**
H03K 19/0185 (2006.01)
H03K 3/037 (2006.01)

(52) **U.S. Cl.**
CPC **H03K 19/018521** (2013.01); **H03K 3/037** (2013.01)

(58) **Field of Classification Search**
CPC H03K 3/037; H03K 19/0185; H03K 19/018507; H03K 19/018521
USPC 326/80, 81; 327/333
See application file for complete search history.

(56) **References Cited**

U.S. PATENT DOCUMENTS

5,963,057	A *	10/1999	Schmitt	H03K 19/00315	326/103
6,064,227	A *	5/2000	Saito	H03K 19/00315	326/68
6,130,557	A *	10/2000	Drapkin	H03K 19/00315	326/68

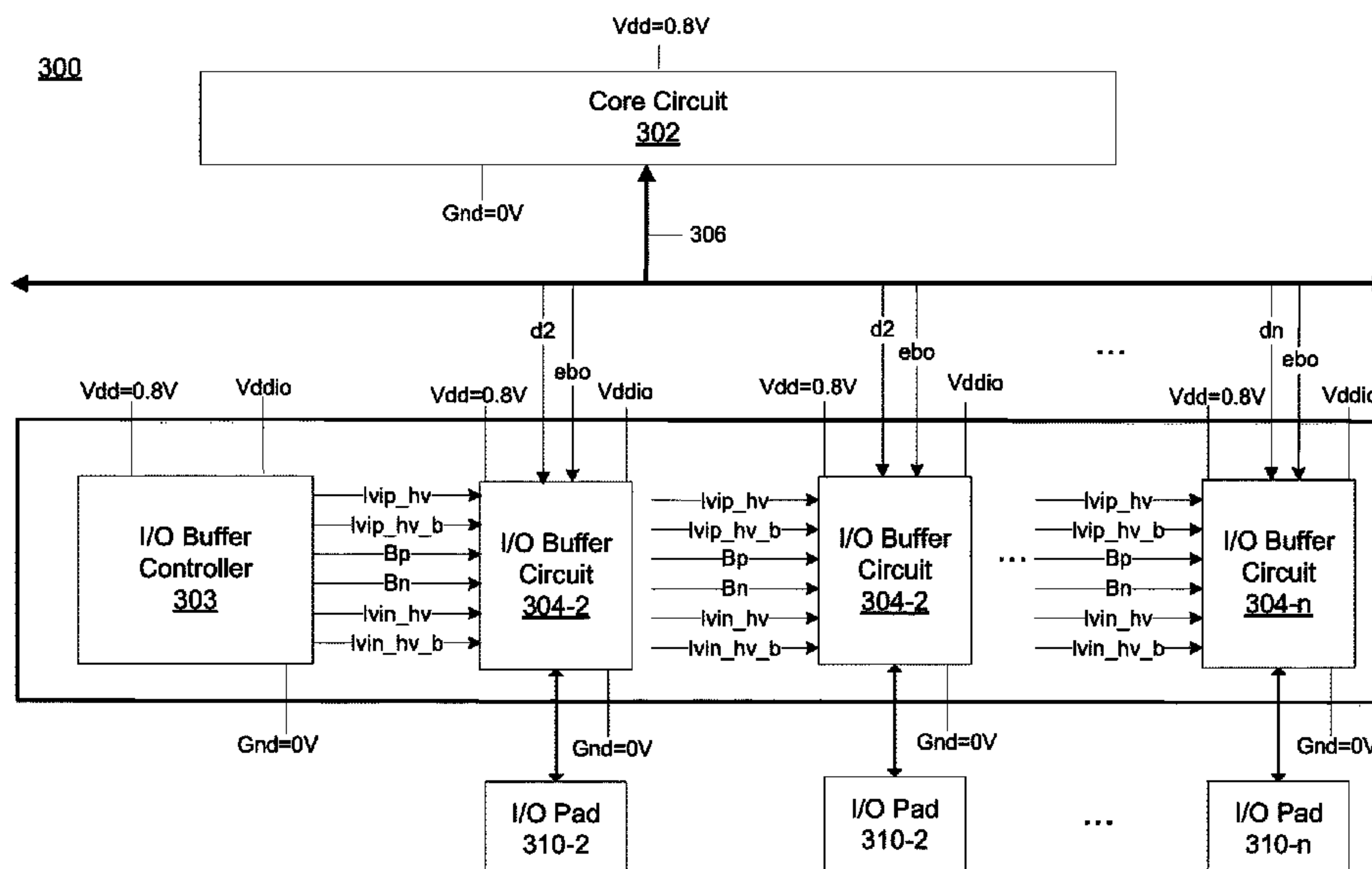
* cited by examiner

Primary Examiner — William Hernandez

(57) **ABSTRACT**

A multi-voltage, high voltage I/O buffer in low-voltage technology is disclosed. In one embodiment, the I/O buffer includes a logic circuit configured to generate a signal based on a data signal and a first control signal. A level shifter is coupled between a supply voltage terminal and a ground terminal, and the level shifter is generates first and second output signals in first and second voltage domains, respectively, at first and second nodes, respectively, based on the signal from the logic circuit. A control circuit is coupled between the second node and a third node. The control circuit transmits the second output signal to the third node when the first control signal is asserted, and the control circuit couples the third node to the ground terminal when the first control signal is not asserted.

20 Claims, 8 Drawing Sheets



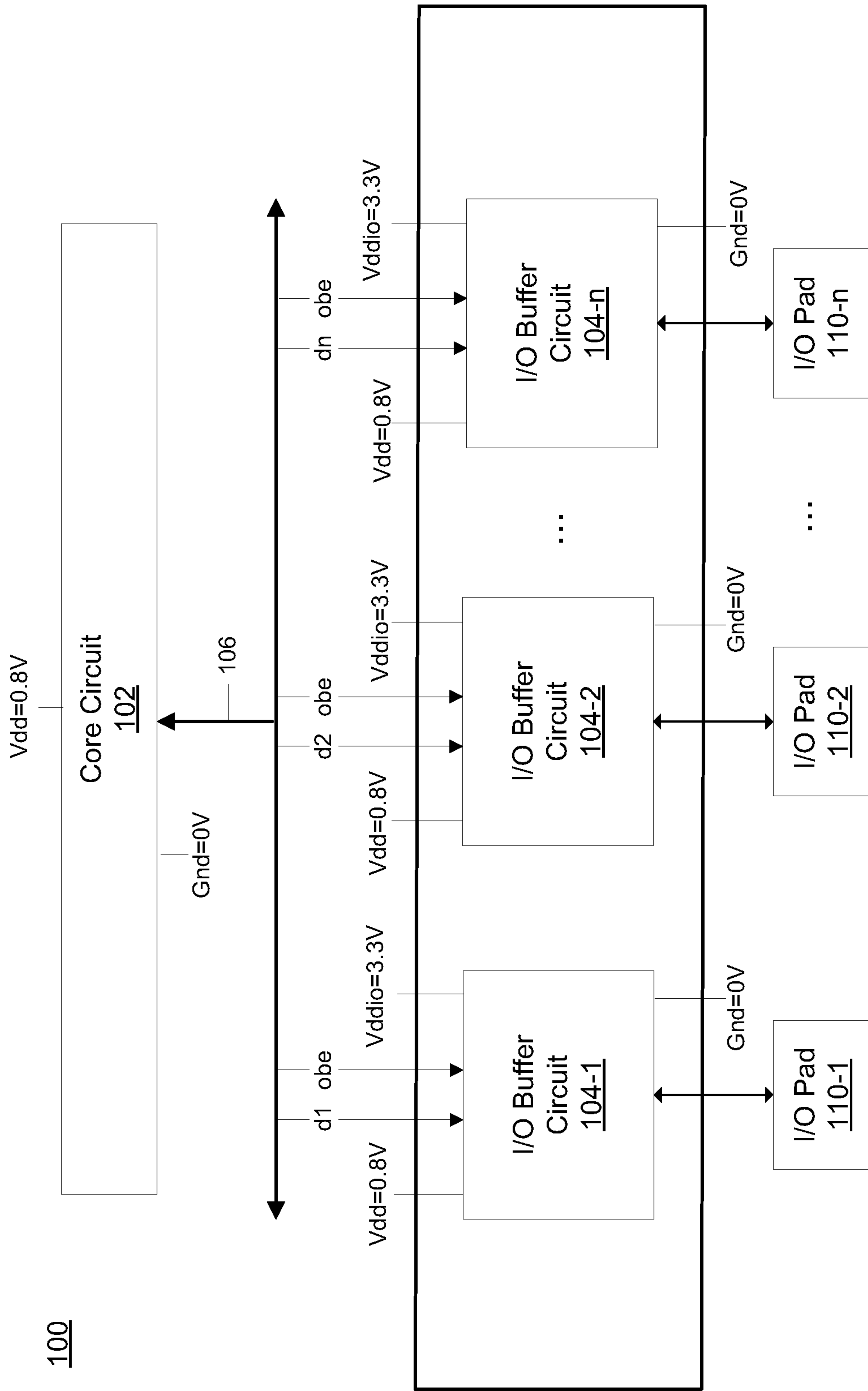


Fig. 1

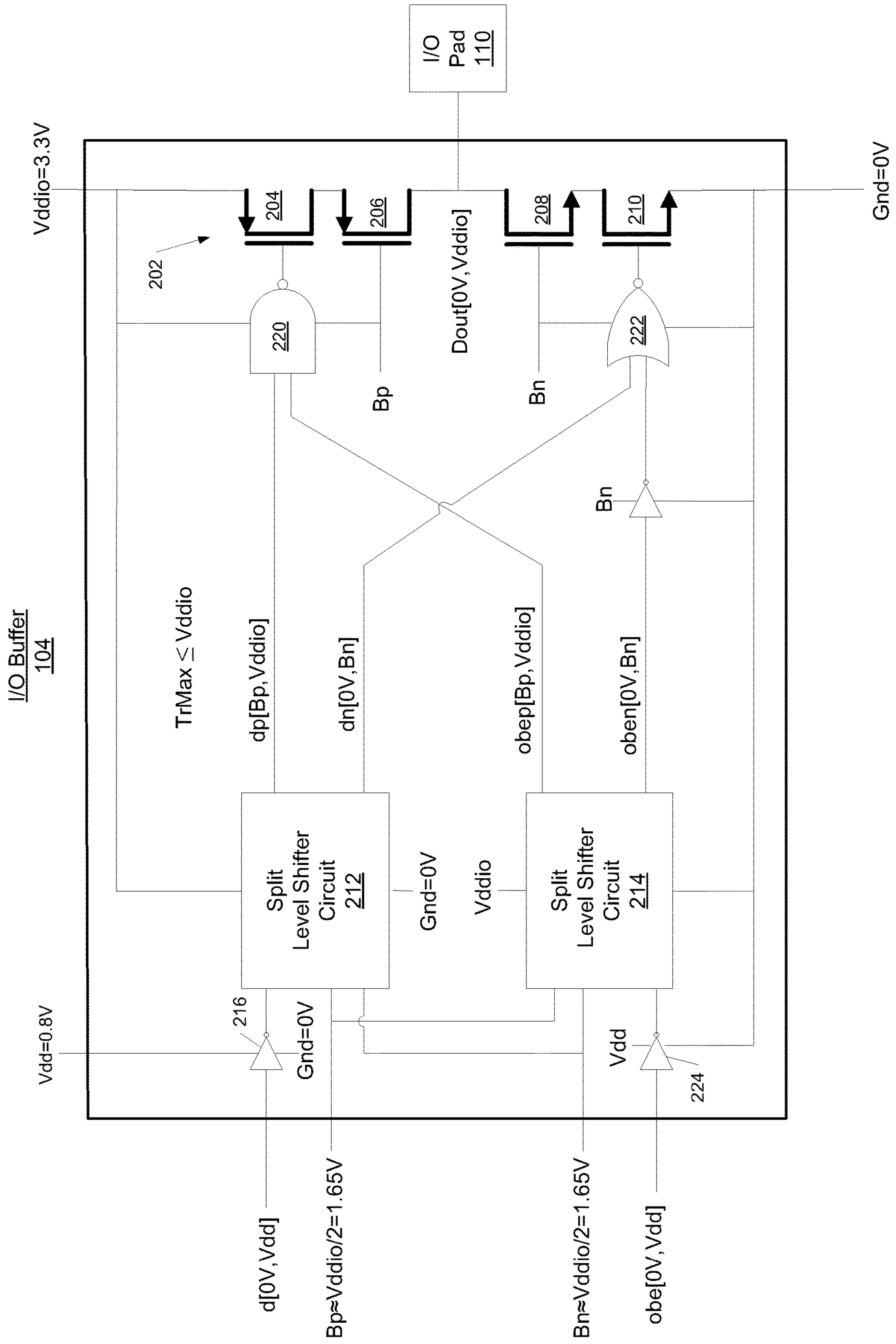


Fig.2

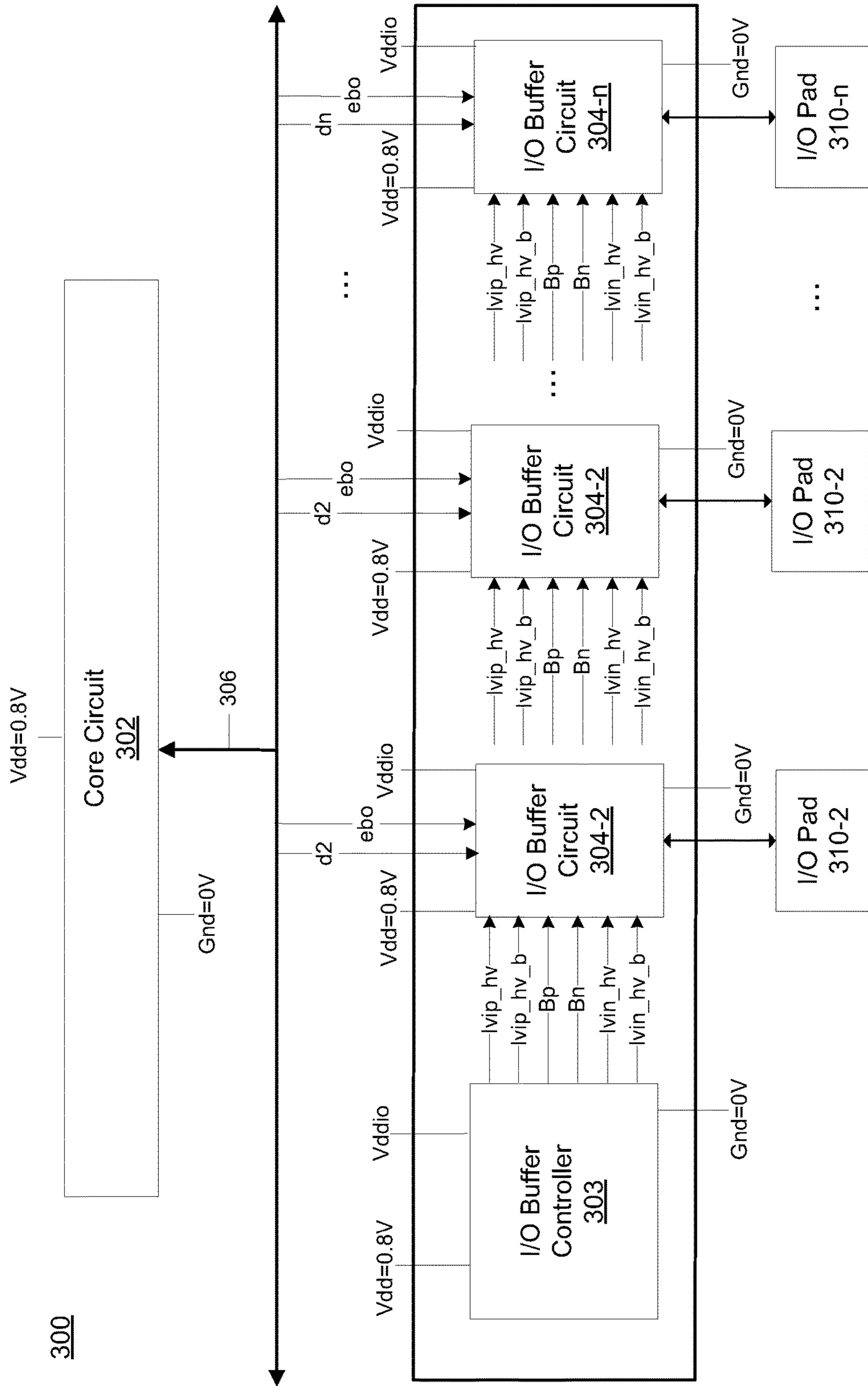


Fig. 3

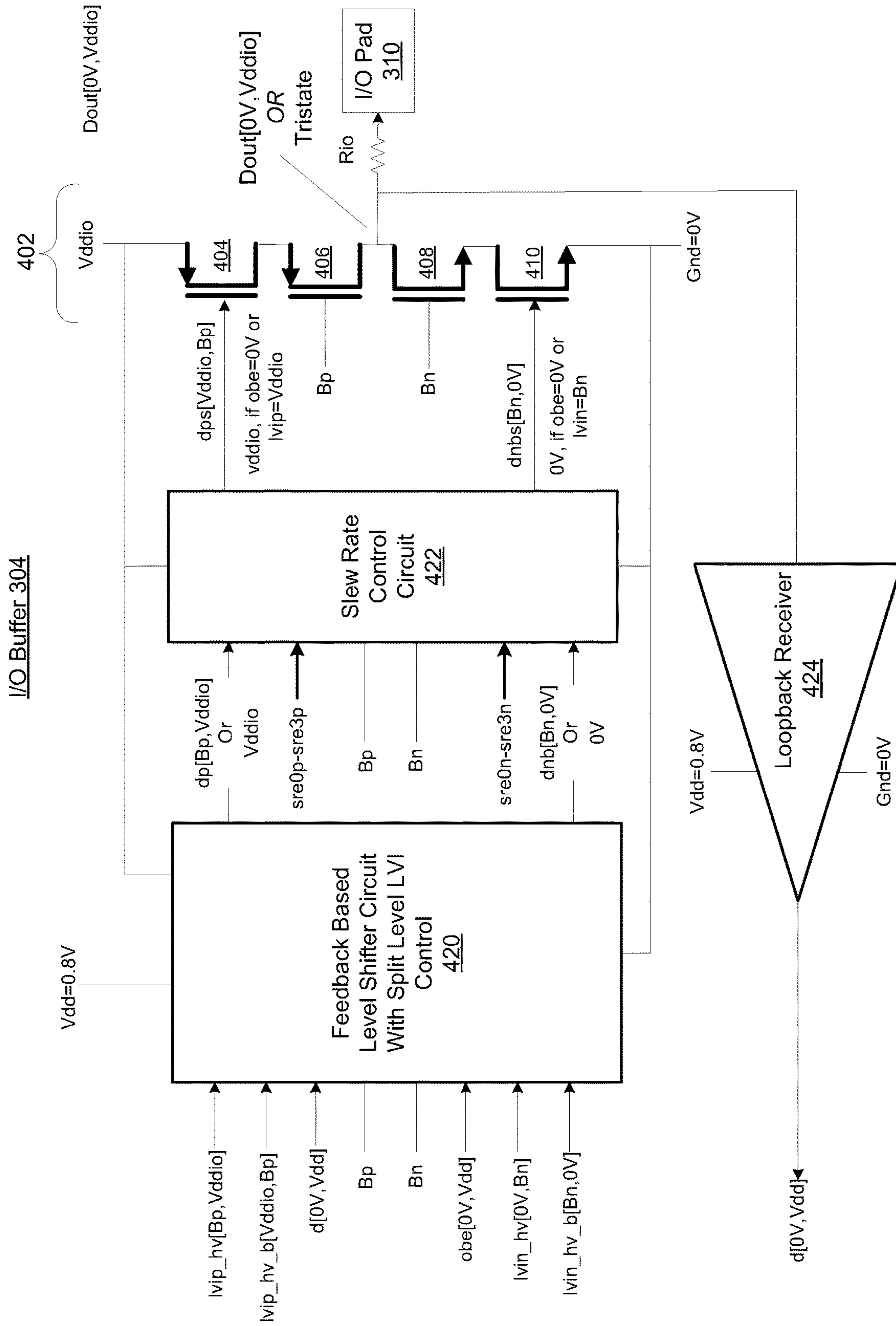


Fig. 4

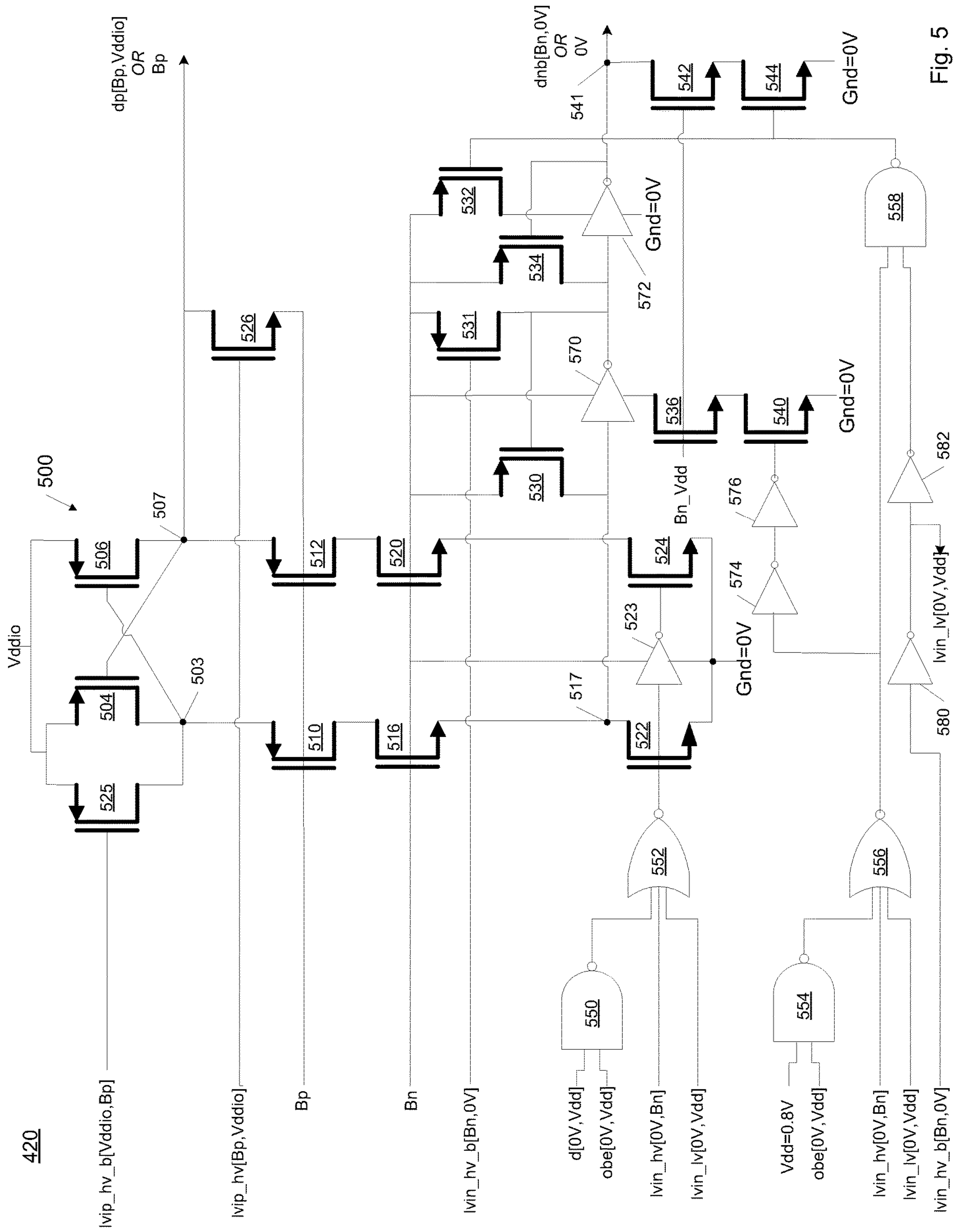


Fig. 5

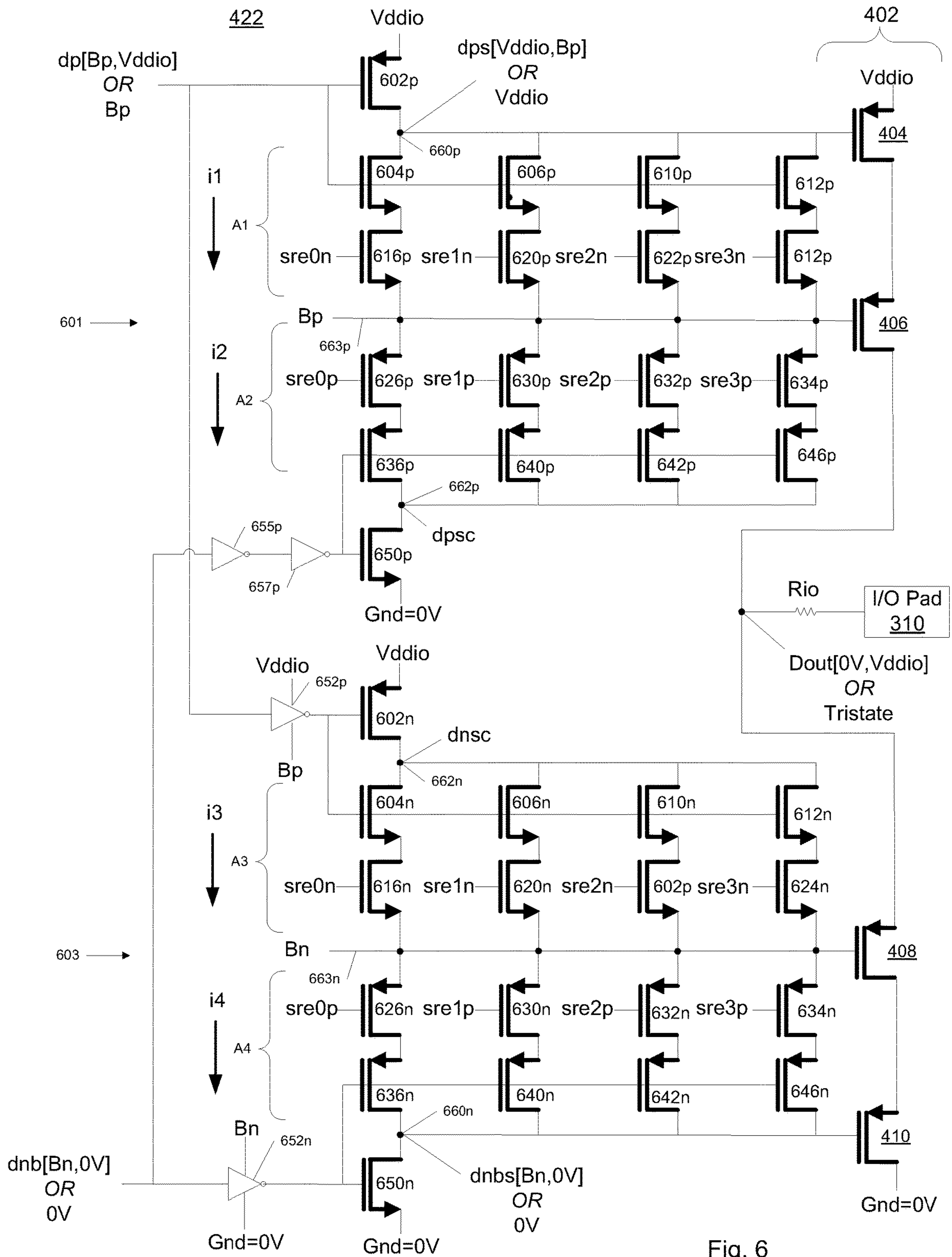


Fig. 6

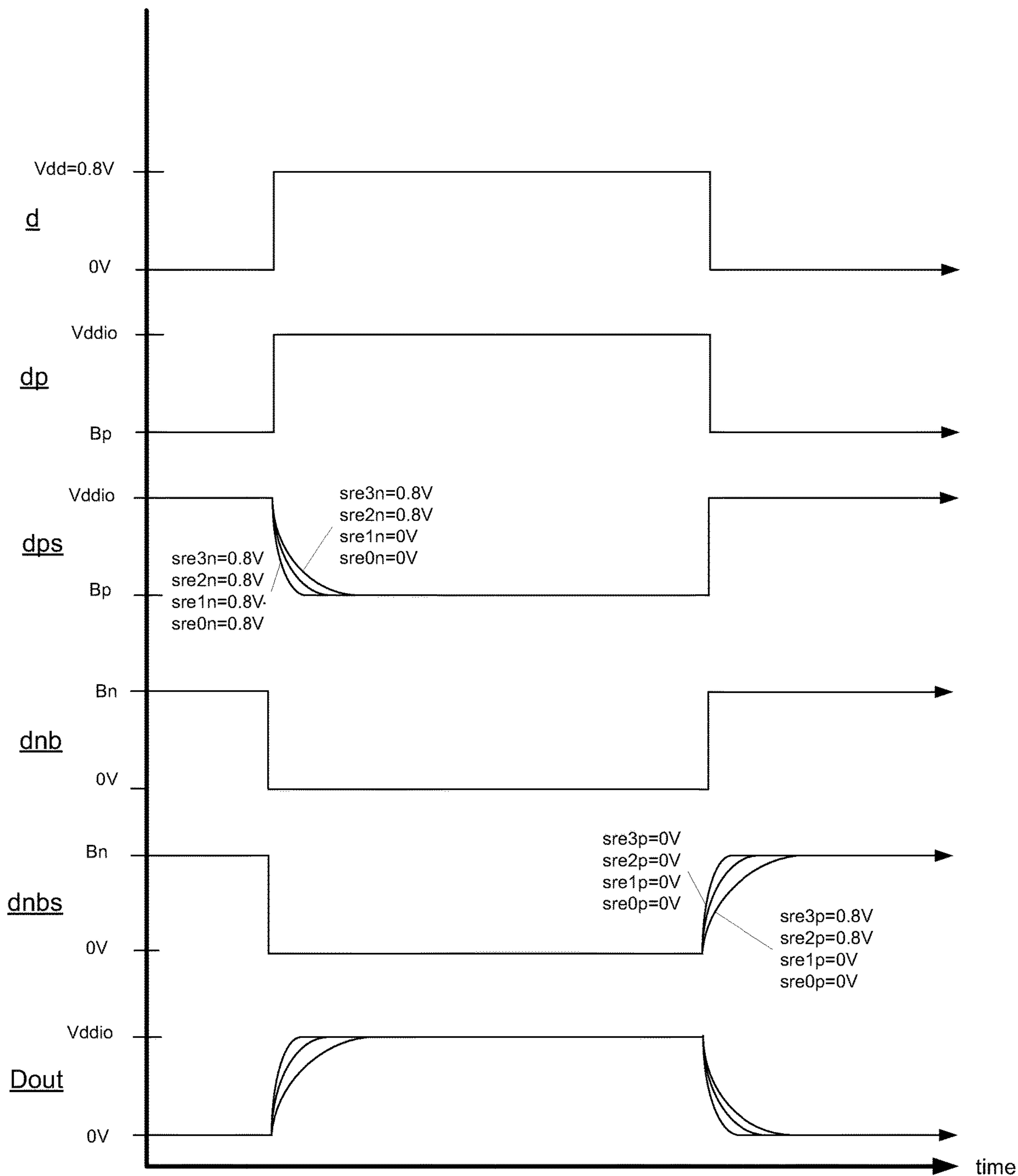


Fig. 7

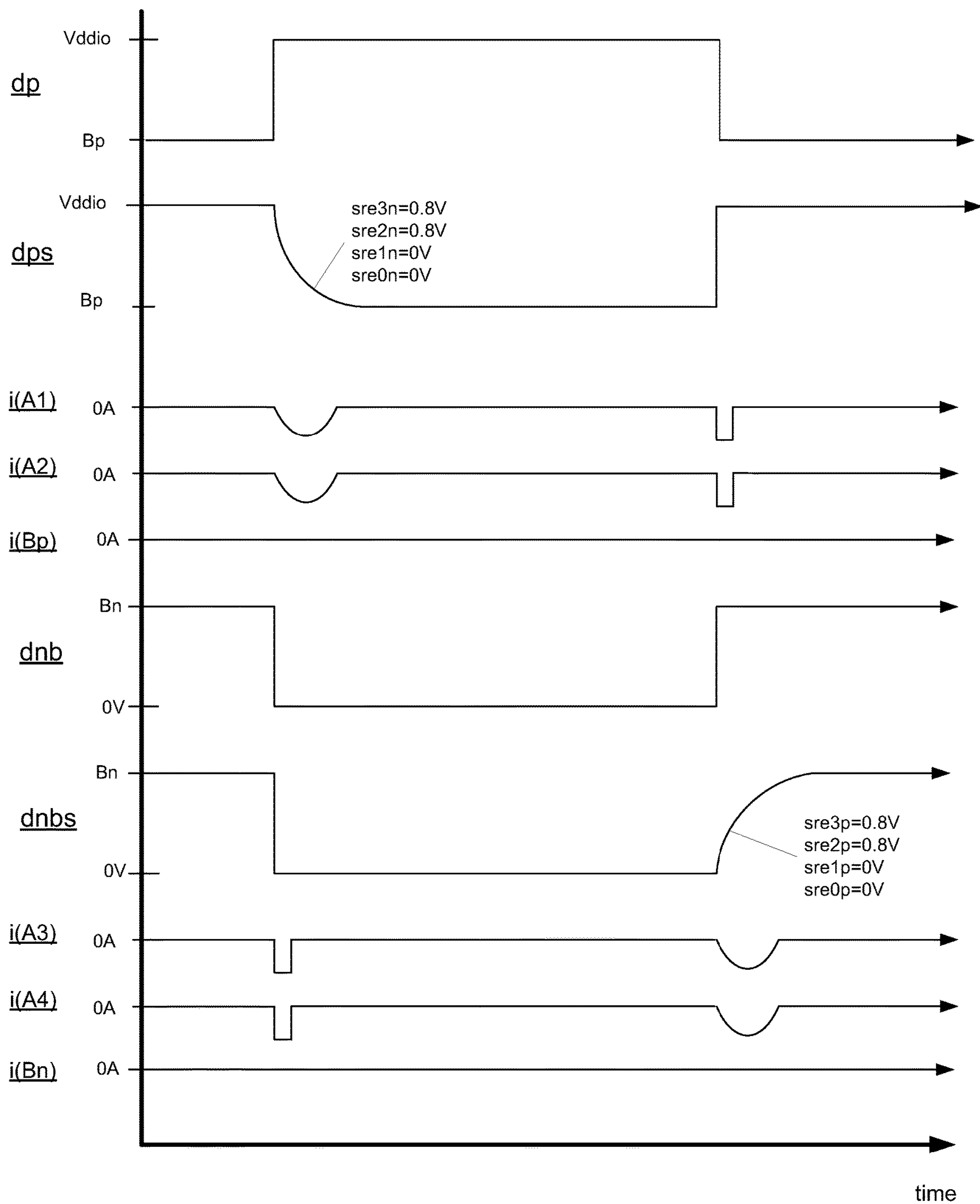


Fig. 8

MULTIVOLTAGE HIGH VOLTAGE IO IN LOW VOLTAGE TECHNOLOGY

BACKGROUND

Integrated circuits (ICs) such as System on Chips (SoCs), microcontrollers (MCUs), etc., communicate with external components such as dynamic random access memory (DRAM), dual data rate (DDR) memory, etc., through input output (I/O) buffers. Generally I/O buffers have input interfaces for communicating with core circuits (e.g., a central processing unit), and output interfaces for communicating with the external components via I/O pads. The input and output interfaces typically operate in different voltage domains. Binary signals in different voltage domains have distinct logic levels. I/O buffers employ level shifters for accommodating the difference in voltage domains by translating logic levels (i.e. logic low voltage and logic high voltage) of signals that pass between the different voltage domains.

BRIEF DESCRIPTION OF THE DRAWINGS

The present technology may be better understood, and its numerous objects, features, and advantages made apparent to those skilled in the art by referencing the accompanying drawings.

FIG. 1 is a block diagram that illustrates an example IC that includes I/O buffers.

FIG. 2 is a mixed schematic and block diagram illustrating an example I/O buffer employed in the IC of FIG. 1.

FIG. 3 is a block diagram that illustrates an example IC that includes I/O buffers according to one embodiment of the present disclosure.

FIG. 4 is a mixed schematic and block diagram illustrating an example I/O buffer that can be employed in the IC of FIG. 3.

FIG. 5 is a schematic diagram illustrating one embodiment of the feedback based level shifter of FIG. 4.

FIG. 6 is a schematic diagram illustrating one embodiment of the slew rate control circuit of FIG. 4.

FIG. 7 are timing diagrams illustrating operational aspects of the slew rate control circuit of FIG. 6.

FIG. 8 are timing diagrams illustrating operational aspects of the slew rate control circuit of FIG. 6.

The use of the same reference symbols in different drawings indicates similar or identical items.

DETAILED DESCRIPTION

FIG. 1 illustrates relevant components of an example IC **100** in block diagram form. IC **100** contains core circuit **102** in data communication with a bank of I/O buffer circuits **104** via data bus **106**. Core circuit **102** is coupled to core supply voltage $V_{dd}=0.8V$, while I/O buffers **104** are coupled to V_{dd} and output supply voltage $V_{ddio}=3.3V$. For purposes of explanation $V_{dd}=0.8V$, it being understood that V_{dd} should not be limited thereto. Also for purposes of, except where noted below, $V_{ddio}=3.3V$ it being understood that V_{ddio} should not be limited thereto.

Core circuit **102** may include various devices including a central processing unit (CPU). I/O buffers **104** can receive data signals d from core circuit **102**. I/O buffers **104** can also receive signals that control their operation. For example I/O buffers **104** can receive an output buffer enable (obe) control signal from core circuit **102**, which disables (tristates) the I/O buffers **104** when $obe=0V$.

With continuing reference to FIG. 1, FIG. 2 illustrates relevant components of an I/O buffer **104** that includes an output stage **202** coupled between output supply voltage $V_{ddio}=3.3V$ and ground $Gnd=0V$. Output stage **202** includes a stack of MOSFETs **204-210** arranged as shown. The drains of P-channel MOSFET **206** and N-channel MOSFET **208** are coupled together and to I/O pad **110**. Output stage **202** drives I/O pad **110** with output data signal $Dout=V_{ddio}=3.3V$ when the input signal $d=V_{dd}=0.8V$, and output stage **202** drives I/O pad **110** with $Dout=Gnd$ when the input signal $d=Gnd$.

The output interfaces of many I/O buffers are often required to operate with an output supply voltage V_{ddio} that exceeds Tr_{Max} , the maximum voltage that can be applied between the gate and source or between the gate and drain of MOSFETs. MOSFETs **206** and **208** are added to protect MOSFETs **204** and **210** from overvoltage damage. For ease of illustration it will be presumed that $Tr_{Max}=1.8V$ for the MOSFETs described herein. The gates of MOSFETs **206** and **208** are biased to voltages $Bp\approx 1.65V$ and $Bn\approx 1.65V$, and as a result neither V_{gs} nor V_{gd} of the MOSFETs **206** or **208** should exceed $Tr_{Max}=1.8V$ while $V_{ddio}=3.3V$. MOSFET **206** decouples the drain of MOSFET **204**, and thus protects it from overvoltage when I/O pad **110** is driven to $0V$ by activated MOSFETs **208** and **210**, and MOSFET **208** decouples the drain of MOSFET **210**, and thus protects it from overvoltage when I/O pad **110** is driven to $V_{ddio}=3.3V$ by activated MOSFETs **204** and **206**.

Split level shifter circuits **212** and **214** receive d and obe , respectively, from core circuit **102** after inversion by inverter circuits **216** and **224**, respectively. Input data signal d and input control signal obe are low voltage signals or binary signals with logic levels $[0V, V_{dd}]$ of the core voltage domain, where $0V$ is logic low, and $V_{dd}=0.8V$ is logic high. Data signal $Dout$ at the I/O pad **110** is a binary signal with logic levels $[0V, V_{ddio}]$ of the output voltage domain, where $0V$ is logic low, and $V_{ddio}=3.3V$ is logic high. Split level shifters **212** and **214** can translate the voltage levels of their respective input signals into high voltage, split level signals in order to accommodate the differences in voltage domains and the Tr_{Max} limitations of MOSFETs **204** and **210**.

Split level shifter **212** translates the low voltage inverted data signal d output from inverter **216** into a pair of high voltage, split level output signals dp and dn , which have logic levels $[Bp, V_{ddio}]$ and $[0V, Bn]$, respectively, where $Bp\approx 1.65V$ and $Bn\approx 1.65V$. NAND gate **220** and NOR gate **222** receive translated signals dp and dn , respectively. The outputs of NAND gate **220** and NOR gate **222** drive the gates of MOSFETs **204** and **210**, respectively, with signals having logic levels $[Bp, V_{ddio}]$ and $[0V, Bn]$, respectively. Under normal circumstances MOSFET **208** will not be damaged when its gate is driven to $Bp=1.65V$, and MOSFET **210** will not be damaged when its gate is driven to $0V$ or $Bn=1.65V$.

Split level shifter **214** translates the low voltage output of inverter **224** into a pair of high voltage, split level output signals $obep$ and $oben$, which have logic levels $[Bp, V_{ddio}]$ and $[Bn, 0V]$, respectively. NAND gate **220** and NOR gate **222** receive $obep$ and $oben$, respectively. If $obe=0V$, split level shifter **214** outputs $obep=Bp=1.65V$, which is a logic low input to NAND gate **220**, and $oben=Bn=1.65V$, which is a logic high input to NOR gate **222**, and as result NAND gate **220** and NOR gate **222** drives the gates of MOSFETs **204** and **210** to $V_{ddio}=3.3V$ and Gnd , respectively, which deactivates MOSFETs **204** and **210**, and places output stage **202** in tri-state. When core circuit **102** asserts obe (e.t., $obe=V_{dd}$), I/O buffer **104** is enabled with NAND gate **220**

and NOR gate **222** essentially operating as inverters that invert translated data signals dp and dn , respectively, before the signals are applied to the gates of MOSFETs **204** and **210**, respectively.

Split level shifters **212** and **214**, and logic gates **220** and **222**, occupy a substantial amount of area of IC **100**, and add complexity to the I/O buffers. Another problem may be that split level shifters **212** and **214** can be physically different or mismatched as a result of semiconductor process differences. The mismatch can lead to timing problems when the operating frequencies of the I/O buffers are high. Disclosed is a multi-voltage, high voltage I/O buffer, which addresses these problems and others.

FIG. **3** illustrates relevant components of an IC **300** in block diagram form, which employs multi-voltage, high voltage I/Os in low voltage technology according to one embodiment of the present disclosure. More particularly IC **300** includes core circuit **302** in data communication with a bank of I/O buffer circuits **304** via data bus **306**. Each of the I/O buffers **304** is controlled by an I/O buffer controller circuit **303**. Core circuit **302** is coupled to core supply voltage $V_{dd}=0.8V$, while I/O buffers **304** are coupled to V_{dd} and output supply voltage V_{ddio} , which can be either 1.8V or 3.3V. The remaining disclosure will presume $V_{ddio}=3.3V$ except where noted. Core circuit **302** may include various devices including a CPU that communicates with components external to IC **300** via I/O buffers **304** and I/O pads **310**. For example, each of the I/O buffers **304** can receive a low voltage data signal d for subsequent transmission to an external component.

Like the I/O buffers of FIG. **1**, I/O buffers **304** receive low voltage obe from core circuit **102**. I/O buffers **304** are tristated when $obe=0V$. I/O buffers **304** also receive high voltage control signals $lvip_{hv}$, $lvin_{hv}$, $lvip_{hv_b}$, and $lvin_{hv_b}$, and bias voltages B_p and B_n from I/O buffer controller **303**. I/O buffer controller **303** generates bias voltages B_p and B_n for I/O buffers **304** based upon V_{ddio} , which can be variable. $B_p \approx 1.65V$, and $B_n \approx 1.65V$ when $V_{ddio}=3.3V$, and $B_p=0V$, and $B_n \approx 1.8V$ when $V_{ddio}=1.8V$. In an alternative embodiment, I/O buffers may internally generate bias voltages B_p and B_n . I/O buffer **304** use of bias voltages B_p and B_n are more fully described below.

I/O buffer controller **303** monitors V_{dd} and/or V_{ddio} by comparing them to respective threshold values V_1 and V_2 . Although not shown I/O buffer controller **303** generates an lvi signal based on the comparison. I/O buffer controller **303** generates $lvi=0V$ when V_{dd} and V_{ddio} exceed their respective thresholds V_1 and V_2 . However, if V_{dd} and/or V_{ddio} are below their respective thresholds, I/O buffer controller **303** generates $lvi=V_{dd}$. Although not shown, I/O buffer controller **303** has a split level shifter, like that shown in FIG. **2**, that level shifts lvi to produce $lvin_{hv}$ and $lvip_{hv}$. $lvip_{hv_b}$ and $lvin_{hv_b}$ are compliments of $lvip_{hv}$ and $lvin_{hv}$, respectively. I/O buffer controller **303** outputs $lvip_{hv}=V_{ddio}$, $lvin_{hv}=B_n$, $lvip_{hv_b}=B_p$ and $lvin_{hv_b}=0V$ if V_{dd} and/or V_{ddio} are below respective threshold values. I/O buffers **304** are tristated if, at the very least, $lvin_{hv}=B_n$.

With continuing reference to FIG. **3**, FIG. **4** illustrates relevant components of an example I/O buffer **304** according to one embodiment of the present disclosure. I/O buffer **304** receives low voltage signals d and obe , high voltage signals $lvip_{hv}$, $lvip_{hv_b}$, $lvin_{hv}$, and $lvin_{hv_b}$, and bias voltages B_p and B_n . I/O buffer **304** includes an output stage **402** that includes a stack of MOSFETs **404-410** arranged as shown between V_{ddio} and Gnd . The drains of P-channel MOSFET **406** and N-channel MOSFET **408** are coupled

together and to I/O pad **310** via resistor R_{io} . Resistor R_{io} is coupled to I/O pad **310** and takes form in a discrete device. Resistor R_{io} is added to control the output impedance of the I/O buffer **302**. Typically, a 50 ohm driver output impedance is sought to match the 50 ohm resistance of the wire or trace that couples the I/O pad **310** to an external component such as a DRAM. Resistor R_{io} is designed to have with a resistance value that, in combination with resistance of MOSFETs **408** and **410**, meets the 50 ohm goal. The gates of MOSFETs **406** and **408** are biased to B_p and B_n , and as a result neither V_{gs} nor V_{gd} of the MOSFETs **406** and **408** should exceed $Tr_{Max}=1.8V$. MOSFETs **406** and **408** protect MOSFETs **404** and **410** from overvoltage as I/O pad **310** is driven to $V_{ddio}=3.3V$ or $Gnd=0V$; MOSFET **406** decouples the drain of MOSFET **404** when I/O pad **310** is driven to $Gnd=0V$ by activated MOSFETs **408** and **410**, and MOSFET **408** decouples the drain of MOSFET **410** when I/O pad **310** is driven to $V_{ddio}=3.3V$ by activated MOSFETs **404** and **406**.

I/O buffer **304** also includes a feedback-based, level shifter circuit **420** (hereinafter FB level shifter **420**) with split level lvi control, a slew rate control circuit **422**, and the loopback receiver circuit **424**, which has an input that is directly connected to the drains of MOSFETs **406** and **408** as shown of output stage **402**. Assuming I/O buffer **304** is not tristated, output stage **402** drives I/O pad **110** to logic high or data $D_{out}=V_{ddio}$ when the input data signal d is logic high or $d=V_{dd}$, and output stage **402** drives I/O pad **310** to logic low or $D_{out}=Gnd$ when the input signal d is logic low or $d=Gnd$.

FB level shifter **420** translates data d into signals with voltage levels that are compatible with the Tr_{Max} limitations of MOSFETs employed in slew rate control circuit **422** and output stage **402**. With continuing reference to FIG. **4**, FIG. **5** illustrates one embodiment of FB level shifter **420**, which generates high-voltage, split-level output signals at nodes **507** and **517**, respectively. The output signals are received by slew rate control circuit **422**. If $obe=V_{dd}$, and if V_{dd} and V_{ddio} are above respective thresholds, FB level shifter shifts input data signal $d[0V, V_{dd}]$ to produce split level signals $dp[B_p, V_{ddio}]$ and $dn[B_n, 0V]$ at nodes **507** and **541**, respectively. Otherwise, FB level shifter **420** outputs B_p and $0V$ at nodes **507** and **541**.

FB level shifter **420** includes split level shifter **500**, which includes P-channel MOSFETs **504-512** and N-channel MOSFETs **516-524** arranged as shown between V_{ddio} and Gnd . Split level shifter **500** is substantially similar to the split level shifters shown in FIG. **2**. One noticeable differences exist. While the outputs of split-level shifters **212** and **214** separately depend on obe and input signal d , respectively, the outputs of level shifter **500** concurrently depend on both obe and d . The gates of MOSFETs **504** and **506** connected to the drains of MOSFETs **506** and **504**, respectively. The drains of MOSFETs **504** and **506** are coupled to the sources of MOSFETs **510** and **512**, respectively. The gates of MOSFETs **510** and **512** are biased to B_p , which is $0V$ if $V_{ddio}=1.8V$, or $1.65V$ if $V_{ddio}=3.3V$. The drains of MOSFETs **510** and **512** are coupled to the drains of MOSFETs **516** and **520**, respectively. The gates of MOSFETs **516** and **520** are biased to B_n , which is $1.8V$ if $V_{ddio}=1.8V$, or $1.65V$ if $V_{ddio}=3.3V$. The sources of MOSFETs **516** and **520** are coupled to the drains of MOSFETs **522** and **524**, respectively. The sources of MOSFETs **522** and **524** are connected to Gnd . The gate of MOSFET **524** is driven output of inverter **523**, while the gate of MOSFETs **22** is driven by the output of NOR gate **552**.

5

FB level shifter **420** also includes NOR and NAND logic gates **550-558**, and inverters **570-582**. Although not shown within FIG. **5** logic gates **550-558**, and inverters **574-582** are coupled between $V_{dd}=0.8V$ and Gnd. Accordingly, logic gates **550-558**, and invertors **574-582** output low voltage signals, or binary signals that switch between $V_{dd}=0.8V$ and Gnd. Inverter **580** generates low voltage lv_{in_lv} based on high-voltage input signal $lv_{in_hv_b}$. Inverter **580** may generate $lv_{in_lv}=V_{dd}$ when V_{ddio} is below threshold V_2 . NAND gate **550** receives low voltage data signal d , and low voltage obe . NOR gate **552** receives the output of NAND gate **550**, low-voltage signal lv_{in_lv} generated by inverter **580**, and high voltage control signal lv_{in_hv} . The output of NOR gate **552** drives the gate of MOSFET **522** and the input of inverter **523**. NAND gate **554** receives obe and $V_{dd}=0.8V$. NOR gate **556** receives the output of NAND gate **554**, high-voltage control signal lv_{in_hv} , and low voltage control signal lv_{in_lv} . NAND gate **558** receives the output of NOR gate **556** and inverter **582**.

FB level shifter **420** further includes MOSFETs **525-544**. MOSFET **525** is coupled in parallel with MOSFET **504** as shown. The gate of MOSFET **525** is controlled by $lv_{ip_hv_b}$. MOSFET **525** couples node **503** to V_{ddio} when $lv_{ip_hv_b}=B_p$. The source of MOSFET **526** is coupled to node **507**, while the drain of MOSFET **526** is biased to B_p . The gate of MOSFET **526** is controlled by lv_{ip_hv} . MOSFET **526** couples output node **507** to B_p when $lv_{ip_hv}=V_{ddio}$. P-channel MOSFET **530** includes a source coupled to bias voltage B_n , and a drain coupled to the input of inverter **570** and the drain of MOSFET **531**. The gate of MOSFET **530** is controlled by the output of the inverter **570**. When the output of inverter **570** is driven to $0V$, MOSFET **530** is activated to couple bias voltage B_n to the input of inverter **570**. P-channel MOSFET **531** is coupled between bias voltage B_n and the output of inverter **470**. The gate of MOSFET **531** is controlled by $lv_{ip_hv_b}$. When $lv_{ip_hv_b}=0V$, MOSFET **531** connects the input of inverter **572** to bias voltage B_n . P-channel MOSFET **534** is also coupled between bias voltage B_n and the input of inverter **572**. The gate of P-channel MOSFET **534** is controlled by the output of inverter **572**. MOSFET **534** connects the input of inverter **572** to B_n when the output of inverter **572** goes to $0V$. P-channel MOSFET **532** is coupled between B_n and inverter **572**. The gate of MOSFET **532** is controlled by the output of NAND **558**. MOSFET **532** provides bias voltage B_n to inverter **572** when the output of NAND gate **558** goes to $0V$. The output of NAND **558** also drives the gate of MOSFET **544** which is coupled between Gnd and protection MOSFET **542**. The gate of MOSFET **542** is biased to $B_n_V_{dd}$. The gate of MOSFET **544** is biased to $B_n_V_{dd}$ and normally activated thereby. Accordingly, output node **541** is pulled down to Gnd when MOSFET **544** is activated by a $0V$ output of NAND gate **558**. The series combination of N-channel MOSFETs **536** and **540** are coupled between inverter **570** and Gnd. The gate of MOSFET **536** is biased to $B_n_V_{dd}$ and normally activated thereby. The gates of MOSFET **540** is controlled by the output of NOR gate **556** via invertors **574** and **576**. When activated MOSFET **540** couples Gnd to inverter **570** the activated MOSFET **536**.

Split-level signals dp and dn at output nodes **507** and **541** of FB level shifter **420** are driven to B_p and 0 , respectively, as noted above if $obe=0V$, $lv_{in_hv}=B_n$, or $lv_{in_lv}=V_{dd}=0.8V$ regardless of the state of data signal d . With $dp=B_p$ and $dn=0V$, I/O buffer **104** will tri-state. If $obe=V_{dd}$, $lv_{in_hv}=0V$, and $lv_{in_lv}=0V$, output nodes **507** and **541** will track low voltage data signal d . More particularly, if $obe=V_{dd}$, $lv_{in_hv}=0V$, and $lv_{in_lv}=0V$, then $dp=B_p$

6

and $dn=B_n$ at output nodes **507** and **541**, respectively, when data signal $d=0V$. When data signal $d=V_{dd}$, $dp=V_{ddio}$ and $dn=0V$ at output nodes **507** and **541**, respectively. In this manner a single level shifter (i.e. MOSFETs **504-524** and inverter **523** arranged as shown) is used to effectively level shift data signal d and obe with split-level lv_{i} control.

FIG. **6** illustrates in schematic form, one embodiment of the slew rate control circuit **422** shown within FIG. **4**. Slew rate control circuit **422** adjusts the slew or rate of transition of split-level data signals dp and dn based upon control signals $sre0p-sre3p$ and $sre0n-sre3n$ provided by core circuit **302**. Slew rate control circuit **422** balances current injected/ejected from lines **663p** and **663n** that provide B_n and B_p , respectively, to various nodes, to reduce voltage perturbations on the lines, which could otherwise create timing mismatches and distort output signal D_{out} . Slew rate control circuit **422** includes sub circuits **601** and **603**. Sub circuit **601** includes MOSFETs **602p-650p** arranged as shown. Sub circuit **603** includes MOSFETs **602n-650n** arranged as shown. Slew rate control circuit **422** also includes invertors **652p**, **652n**, **655p**, and **655n**. Inverter **652p** drives the gate of MOSFET **602n** based on input signal $dp[B_p, V_{ddio}]$ or B_p , while inverter **652n** drives the gate of MOSFET **650p** based upon input signal $dn[B_n, 0V]$ or $0V$. Output nodes **660p** and **660n** are coupled to the gates of MOSFETs **404** and **410**, respectively, and as a result the signals at output nodes **660p** and **660n** control the output stage **402**.

With continuing reference to FIG. **6**, sub-circuit **601** includes P-channel MOSFET **602**, which is coupled between V_{ddio} and node **660p**. The gate of MOSFET **602p** is controlled by i.e., $dp[B_p, V_{ddio}]$ or B_p , the signal generated by FB level shifter **420** at output node **507** shown in FIG. **5**. The drains of each of the N-channel MOSFETs **604p-612p** are coupled to node **660p**, while the gates of these MOSFETs are controlled by $dp[B_p, V_{ddio}]$ or B_p . The sources of MOSFETs **604p-612p** are coupled to the drains of N-channel MOSFET **616p-624p**, respectively. The gates of MOSFETs **616p-624p** are controlled by $sre0n-sre3n$, respectively. MOSFET **602p** is activated when MOSFETs **604p-612p** are deactivated, and vice versa. When MOSFET **602p** is activated, node **660p** is driven to V_{ddio} . While MOSFET **602p** is deactivated, and MOSFETs **604p-612p** are activated, one or more activated MOSFETs **616p-624p** couple B_p to node **660p**. When node **660p** transitions from V_{ddio} to B_p , current it is drained from node **660p** through group **A1** of activated MOSFETs until the voltage at node **660p** drops to B_p . The rate of transition of the voltage at node **660p** depends upon the number of activated MOSFETs in group **A1**. P-channel MOSFETs **626p-634p** have sources connected to B_p as shown. P-channel MOSFETs **636p-646p** have sources coupled to the respective drains of MOSFETs **626p-634p**. The drains of MOSFETs **636p-646p** are coupled to the drain of N-channel MOSFETs **650p**. The source of MOSFET **650p** is coupled to Gnd. The gate of MOSFET **650p** is controlled by the output of inverter **657p**. MOSFET **650p** is activated while MOSFETs **636p-646p** are deactivated, and vice versa. When MOSFET **650** is activated, node **662p** is pulled down to Gnd. The gates of MOSFETs **626p-634p** are controlled by $sre0p-sre3p$, respectively. With MOSFETs **636p-646p** activated by the output of inverter **657pn**, node **662p** is coupled to B_p by activated MOSFETs in group **A2**. As a result node **662p** will charge up to B_p via current i_2 . The rate at which node **662p** charges up to B_p depends upon number of MOSFETs activated in group **A2**. B_p is coupled to the gate of MOSFET **406**.

Sub-circuit **603** includes P-channel MOSFET **650n**, which is coupled between Gnd and node **660n**. The gate of

MOSFET 650 n is controlled by inversion of dnb[B n ,0V] or 0V, the signal generated by FB level shifter 420 at output node 541 shown in FIG. 5. The drains of each of the P-channel MOSFETs 636 n -646 n are coupled to node 660 n , while the gates of these MOSFETs are controlled by the inversion of dnb[B n ,0V] or 0V. The sources of MOSFETs 636 n -646 n are coupled to the drains of P-channel MOSFET 626 n -634 n , respectively. The gates of MOSFETs 626 n -634 n are controlled by sre0 p -sre3 p , respectively. MOSFET 602 n is activated when MOSFETs 604 n -612 n are deactivated, and vice versa. When MOSFET 602 n is activated, node 662 n is driven to V $ddio$. While MOSFET 602 n is deactivated, and MOSFETs 604 n -612 n are activated, one or more activated MOSFETs 616 n -624 n couple B n to node 662 n . When node 662 n transitions from V $ddio$ to B n , current i3 is drained from node 662 n through activated MOSFETs in group A3 until the voltage at node 662 n drops to B n . The rate of transition of the voltage at node 662 n depends upon the number of activated MOSFETs in group A3. P-channel MOSFETs 626 n -634 n have sources connected to B n as shown. P-channel MOSFETs 636 n -646 n have sources coupled to the respective drains of MOSFETs 626 n -634 n . The drains of MOSFETs 636 n -646 n are coupled to the drain of N-channel MOSFETs 650 n . The source of MOSFET 650 n is coupled to Gnd. The gate of MOSFETs 650 n and MOSFETs 636 n -646 n are controlled by the output of inverter 652 n . MOSFET 650 n is activated while MOSFETs 636 n -646 n are deactivated, and vice versa. When MOSFET 650 n is activated, node 660 n is pulled down to Gnd. The gates of MOSFETs 626 n -634 n are controlled by sre0 p -sre3 p , respectively. With MOSFETs 636 n -646 n activated by the output of inverter 650 n , node 660 n is coupled to B n by activated MOSFETs 626 n -634 n in group A4. As a result node 660 n will charge up to B n via current i4. The rate at which node 660 n charges up to B n depends upon number of activated MOSFETs in group A4.

As noted slew rate control circuit 422 adjusts slew rate of output signals dp and do from FB level shifter 420. FIG. 7 illustrates timing diagrams that better explain slew rate adjustment. The timing diagrams presume I/O buffer 304 is not tristated by obe=V dd =0.8V, lvin $_{hv}$ =B n , or lvin $_{lv}$ =V dd =0.8V. FIG. 7 shows timing diagrams for input signal d to FB level shifter 420, and timing diagrams for corresponding output signals dp and do from FB level shifter 420. FIG. 7 shows additional timing diagrams for dps and dnsb, which are the signals generated at node 660 p and 660 n , respectively, which in turn drive the gates of MOSFETs 404 and 410, respectively, of the output stage 402. Lastly FIG. 7 shows a timing diagram for Dout. As shown, the rate at which dps falls depends upon sre0 n -sre3 n , and the rate at which dnsb rises depends upon sre0 p -sre3 p . Since dps and dnsb control the output stage 402, the rate at which Dout rises and falls also depends upon sre0 p -sre3 p and sre0 n -sre3 n .

FIG. 8 illustrates timing diagrams dp, dps, dnb, and dnbs from FIG. 7. In addition FIG. 8 illustrates timing diagrams for i1-i4. FIG. 8 shows that current i1, which flows into line 663 p , equals current i2, which flows out of line 663 p when sre0 p -sre3 p equal sre0 n -sre3 n , respectively. As a result, no net current i(B p) is injected into or drained from line 663 n . As a result, B p is stabilized during signal switching. Likewise FIG. 8 shows that current i3, which flows into line 663 n , equals current i3, which flows out of line 663 n when sre0 p -sre3 p equal sre0 n -sre3 n , respectively. As a result, no net current i(B n) is injected into or drained from line 663 n . As a result, B n is stabilized during signal switching.

Returning to FIG. 4, I/O buffer 304 includes a loopback receiver 424 with an input coupled directly to the output of the drains MOSFETs 406 and 408 as shown. ICs employ loopback so that the core circuits can see the data signals d that they send to the I/O buffers. In the past a receiver is provided with an input coupled to the I/O pad. The receiver receives the output signal Dout from the output stage of the I/O buffer after the output signal Dout passes through Rio. Unfortunately, resistor Rio degrades the signal received at the input of the receiver. Loopback receiver 424 is coupled directly to the output stage 402 and translates signal Dout back into signal d for subsequent processing by core circuit 302 in order to determine operational aspects.

An integrated circuit (IC) is provided that includes an input/output (I/O) buffer which in turn includes a logic circuit, a level shifter, and a control circuit. The logic circuit is configured to generate a signal based on a data signal and a first control signal. The level shifter is coupled between a supply voltage terminal and a ground terminal. The level shifter is configured to generate first and second output signals in first and second voltage domains, respectively, at first and second nodes, respectively, based on the signal from the logic circuit. The control circuit is coupled between the second node and a third node. The control circuit transmits the second output signal to the third node when the first control signal is asserted, and the control circuit couples the third node to the ground terminal when the first control signal is not asserted. The I/O buffer may further include an I/O pad, and an output stage for driving the I/O pad. The output stage may include first and second transistors that are controlled by the voltages at the first and third nodes, respectively. The I/O buffer may further include an I/O pad, and an output stage for driving the I/O pad. The output stage may include first and second P-channel MOSFETs coupled in series, and first and second N-channel MOSFETs coupled in series, wherein the series coupled P-channel MOSFETs are coupled in series with the series coupled N-channel MOSFETs between the supply voltage terminal that is configured to receive a supply voltage V $ddio$ and the ground terminal configured to receive a ground voltage. Drains of the second P-channel MOSFET and the first N-channel MOSFET can be connected together and to the I/O pad. The gate of the second P-channel MOSFET can be biased to V $ddio$ /2. A gate of the first N-channel MOSFET can be biased to V $ddio$ /2. A gate of the first P-channel MOSFET may be controlled by the voltage at the first node, while a gate of the second N-channel MOSFET is controlled by the voltage at the third node. The level shifter may include a first stack of MOSFETs coupled between the supply voltage terminal and the ground terminal. The first stack may include first and second P-channel MOSFETs coupled in series, and first and second N-channel MOSFETs coupled in series. The series coupled P-channel MOSFETs and the series coupled N-channel MOSFETs of the first stack can be coupled in series between the supply voltage terminal and the ground terminal. The source and drain of the first and second N-channel MOSFETs of the first stack can be connected to each other and to the second terminal. The I/O buffer may further include a pair of inverters coupled in series between the second and third nodes. The IC may further include a core circuit configured to generate the data signal and the first control signal in an input voltage domain, wherein the first, second, and input voltage domains are distinct from each other.

In another embodiment an integrated circuit is provided that includes an I/O buffer which in turn includes an I/O pad, logic circuit, a level shifter, and a control circuit. The logic

circuit is configured to generate a signal based on first and second input signals. The level shifter is configured to generate first and second output signals based on the signal from the logic circuit. The control circuit is configured to receive the second output signal and the first input signal. The output stage is configured to drive the I/O pad, wherein the output stage comprises first and second transistors. The control circuit is configured to activate or deactivate the second transistor based on the second output signal while the first input signal is asserted, and the control circuit is configured to deactivate the second transistor while the first input signal is not asserted. The first and second input signals may have input logic levels [LVI,HVI] where LVI defines a voltage for logic low and HVI defines a voltage for logic high. The first output signal may have first logic levels [LV1,HV1] where LV1 defines a voltage for logic low and HV1 defines a voltage for logic high. The second output signal may have second logic levels [LV2,HV2] where LV2 defines a voltage for logic low and HV2 defines a voltage for logic high. HV1, HV2, and HVI should be distinct from each other. The first input signal can be asserted when it is set to HVI, and the first input signal should not be asserted when it is set to LVI. The output stage may include first and second P-channel MOSFETs coupled in series, first and second N-channel MOSFETs coupled in series, wherein the series coupled P-channel MOSFETs are coupled in series with the series coupled N-channel MOSFETs between a supply voltage terminal configured to receive a supply voltage Vddio, and a ground terminal configured to receive a ground voltage. The first P-channel MOSFET can be the first transistor, and the second N-channel MOSFET can be the second transistor. Drains of the second P-channel MOSFET and the first N-channel MOSFET can be connected together and to the I/O pad. A gate of the second P-channel MOSFET can be biased to $V_{ddio}/2$. A gate of the first N-channel MOSFET can be biased to $V_{ddio}/2$. The level shifter may include a first stack of MOSFETs, which in turn includes first and second P-channel MOSFETs coupled in series, and first and second N-channel MOSFETs coupled in series. The series coupled P-channel MOSFETs and the series coupled N-channel MOSFETs of the first stack can be coupled in series between the supply voltage terminal and the ground terminal. The source and drain of the first and second N-channel MOSFETs of the first stack can be connected to each other and to a first terminal where the second output signal is generated. The logic circuit can receive a third input signal, and wherein the logic circuit is configured to generate the output signal based on the first, second and third input signals. The IC of this embodiment may further include a core circuit configured to generate the first and second input signals, wherein the first input signal comprises an I/O buffer enable signal, and wherein the second input signal comprises a data signal.

In yet another embodiment an integrated circuit (IC) is provided that includes an I/O buffer, which in turn includes an I/O pad, an output stage, a logic circuit, a level shifter, and a control circuit. The output stage is configured to drive the I/O pad. The logic circuit is configured to generate a binary output signal based on first and second binary input signals. The level shifter is configured to generate first and second binary output signals based on the binary output signal from the logic circuit. The control circuit is configured to receive the first binary input signal and the second binary output signal. The control circuit is configured to control the output stage based on the first binary input signal and the second binary output signal. The output stage may include first and second P-channel MOSFETs coupled in

series, a first and second N-channel MOSFETs coupled in series, wherein the series coupled P-channel MOSFETs are coupled in series with the series coupled N-channel MOSFETs between a supply voltage terminal configured to receive a supply voltage Vddio and a ground terminal configured to receive a ground voltage. Drains of the second P-channel MOSFET and the first N-channel MOSFET can be connected together and to the I/O pad. A gate of the second P-channel MOSFET can be biased to $V_{ddio}/2$. A gate of the first N-channel MOSFET can be biased to $V_{ddio}/2$. The control circuit may include first and second invertors coupled in series, and an activation circuit, wherein the first inverter is configured to receive the second binary output signal, wherein the activation circuit is configured to deactivate the second inverter when the first binary input signal is not asserted, and wherein the activation circuit is configured to activate the second inverter when the first binary input signal is asserted. The control circuit may include an output configured to control the voltage at a gate of the second N-channel MOSFET, wherein the control circuit is configured to activate or deactivate the second N-channel MOSFET based on the second binary output signal while the first binary input signal is asserted, and wherein the control circuit is configured to deactivate the second N-channel MOSFET while the first binary input signal is not asserted. The first and second binary input signals may have input logic levels [LVI,HVI] where LVI defines a voltage for logic low and HVI defines a voltage for logic high. The first binary output signal may have first logic levels [LV1,HV1] where LV1 defines a voltage for logic low and HV1 defines a voltage for logic high. The second binary output signal may have second logic levels [LV2,HV2] where LV2 defines a voltage for logic low and HV2 defines a voltage for logic high. HV1, HV2, and HVI should be distinct from each other. The IC of this embodiment may further include a core circuit configured to generate the first and second binary input signals, wherein the first binary input signal comprises an I/O buffer enable signal, and wherein the second binary input signal comprises a data signal. The level shifter may include a first stack of MOSFETs which in turn includes first and second P-channel MOSFETs coupled in series, first and second N-channel MOSFETs coupled in series, wherein the series coupled P-channel MOSFETs and the series coupled N-channel MOSFETs of the first stack are coupled in series between the supply voltage Vddio terminal and the ground terminal. The source and drain of the first and second N-channel MOSFETs of the first stack may be connected to each other and to a first terminal where the second binary output signal is generated.

An integrated circuit (IC) is also provided that in one embodiment includes an input/output (I/O) buffer, which in turn includes an I/O pad, a logic circuit, a level shifter, and a control circuit. The logic circuit is configured to generate a logic signal based on a data input signal in an input voltage domain and a first control signal. The level shifter is coupled between a supply voltage terminal and a ground terminal, wherein the level shifter is configured to generate first and second outputs in first and second voltage domains, respectively, at first and second nodes, respectively, based on the logic signal. The control circuit is coupled between the second node and a third node, and configured to receive the first control signal in the input voltage domain, and a second control signal in the second voltage domain. The control circuit is configured to transmit the second output to the third node when the first and second control signals are not asserted, and the control circuit is configured to couple the third node to the ground terminal when the first or second

signal is asserted. The input, first, and second output voltage domains are distinct from each other. The I/O buffer may further include an output that stage includes first and second P-channel MOSFETs coupled in series, and first and second N-channel MOSFETs coupled in series. The series coupled P-channel MOSFETs can be coupled in series with the series coupled N-channel MOSFETs between the supply voltage terminal that is configured to receive supply voltage V_{ddio} , and the ground terminal. The drains of the second P-channel MOSFET and the first N-channel MOSFET can be connected together and to the I/O pad. A gate of the second P-channel MOSFET can be configured to receive a bias voltage $B_p = V_{ddio}/2$. The gate of the first N-channel MOSFET can be configured to receive a bias voltage $B_n = V_{ddio}/2$. A gate of the first P-channel MOSFET can be controlled by the voltage at the first node. A gate of the second N-channel MOSFET can be controlled by the voltage at the third node. The split level shifter may include a first stack of MOSFETs, which in turn includes first and second P-channel MOSFETs coupled in series, and first and second N-channel MOSFETs coupled in series. The series coupled P-channel MOSFETs and the series coupled N-channel MOSFETs of the first stack can be coupled in series between the supply voltage terminal and the ground terminal. A source and drain of the first and second N-channel MOSFETs of the first stack can be connected to each other and to a terminal where the second output is generated. The logic circuit of the IC can be configured to generate the logic signal based on the data input signal, the first control signal, and the second control signal. The I/O buffer may further include a discrete resistor device coupled between the output stage and the I/O pad, and a receiver having an input connected between the output stage and the discrete resistor, and an output configured to generate a loopback signal in the input voltage domain based on a signal generated at the output stage. The discrete resistor can be configured with an impedance, which when combined with an impedance of the output stage, matches an impedance of a conductive trace when it is connected to the I/O pad. The I/O buffer may further include a slew rate control circuit coupled between the split level shifter and the output stage. The slew rate control circuit can generate an adjusted first output by adjusting a falling edge slew rate of the first output. The output stage is configured to receive the adjusted first output.

Another integrated circuit (IC) is provided that includes an input/output (I/O) buffer, which in turn includes an I/O pad, an output stage, a discrete resistor coupled between the output stage and the I/O pad, a first receiver, and a split domain level shifter. The first receiver has an input coupled between the output stage and the discrete resistor. The split domain level shifter is configured to generate first and second outputs in first and second voltage domains, respectively, based on an input logic signal in an input voltage domain. The output stage is configured to drive the I/O pad via the discrete resistor based on the first and second outputs. The first receiver is configured to generate a first signal based on a signal generated by the output stage and provided to the discrete resistor. The discrete resistor can be configured with an impedance, which when combined with an impedance of the output stage, matches an impedance of a conductive trace when it is connected to the I/O pad. The I/O buffer may further include a second receiver with an input coupled to the I/O pad, wherein the second receiver is configured to generate a second signal based on a signal received at the I/O pad from a device external to the IC. The other IC may further include a core circuit coupled to the I/O buffer, the I/O buffer may further include a logic circuit

configured to receive an input data signal from the core circuit, and the logic circuit can be configured to generate the input logic signal provided to the split domain level shifter. The core circuit can receive the first signal from the first receiver for subsequent processing. The logic circuit can be configured to receive a first control signal from the core circuit, and the logic circuit can be configured to generate the input logic signal provided to the split domain level shifter based on the input data signal and the first control signal.

Yet another integrated circuit (IC) is provided that includes an input/output (I/O) buffer that includes output stage coupled to an I/O pad, a level shifter, and a slew rate control circuit. The level shifter is configured to generate first and second output signals in first and second voltage domains, respectively, based on an input signal. The slew rate control circuit is coupled between the split level shifter and the output stage. The slew rate control circuit is configured to generate an adjusted first output signal by adjusting a falling edge slew rate of the first output signal. The output stage is configured to receive the adjusted first output signal and configured to drive the I/O pad based on the adjusted first output signal. The I/O buffer may further include an inverter for inverting the second output signal to generate an inverted second output signal, and the slew rate control circuit can generate an adjusted, inverted second output signal by adjusting a rising edge slew rate of the inverted second output signal. The output stage can receive the adjusted, inverted second output signal and may be configured to drive the I/O pad based on the adjusted, inverted second output signal. The slew rate control circuit can be configured to generate an adjusted second output signal by adjusting a rising edge slew rate of the second output signal, and the output stage can be configured to receive the adjusted second output signal and configured to drive the I/O pad based on the adjusted second output signal. The slew rate control circuit can receive a plurality of first signals, and the slew rate control circuit can adjust the falling edge slew rate of the first output signal based on the plurality of first signals. The IC of this embodiment may further include a core circuit that is configured to provide the plurality of first signals to the slew rate control circuit. The slew rate control circuit may include a P-channel MOSFET comprising a gate, a source, and a drain, wherein the gate is configured to receive the first output signal, and the source is coupled to a terminal that is configured to receive a supply voltage V_{ddio} . The slew rate control circuit may further include a first plurality of N-channel MOSFETs each comprising a gate, a source, and a drain, wherein the gates of the first plurality of N-channel MOSFETs are coupled to receive the first output signal, wherein the drains of the first plurality of N-channel MOSFETs are coupled to the drain of the P-channel MOSFET. Lastly the slew rate control circuit may also include a second plurality N-channel MOSFETs each comprising a gate, a source, and a drain, wherein the gates of the second plurality of N-channel MOSFETs are coupled to receive the plurality of first signals, respectively, wherein the drains of the second plurality of N-channel MOSFETs are coupled to the sources of the first plurality of N-channel MOSFETs, respectively, and wherein the drains of the second plurality N-channel MOSFETs are coupled to receive a bias voltage.

Although the present invention has been described in connection with several embodiments, the invention is not intended to be limited to the specific forms set forth herein. On the contrary, it is intended to cover such alternatives,

13

modifications, and equivalents as can be reasonably included within the scope of the invention as defined by the appended claims.

What is claimed is:

1. An integrated circuit (IC) comprising:
 - an input/output (I/O) buffer comprising:
 - a logic circuit configured to generate a signal based on a data signal and a first control signal;
 - a level shifter coupled between a supply voltage terminal and a ground terminal, wherein the level shifter is configured to generate first and second output signals in first and second voltage domains, respectively, at first and second nodes, respectively, based on the signal from the logic circuit;
 - a control circuit coupled between the second node and a third node, wherein the control circuit transmits the second output signal to the third node when the first control signal is asserted, and wherein the control circuit couples the third node to the ground terminal when the first control signal is not asserted.
2. The IC of claim 1 wherein the I/O buffer further comprises:
 - an I/O pad;
 - an output stage for driving the I/O pad, the output stage comprising first and second transistors;
 - wherein the first and second transistors are controlled by the voltages at the first and third nodes, respectively.
3. The IC of claim 1 wherein the I/O buffer further comprises:
 - an I/O pad;
 - an output stage for driving the I/O pad, the output stage comprising:
 - first and second P-channel MOSFETs coupled in series;
 - first and second N-channel MOSFETs coupled in series;
 - wherein the series coupled P-channel MOSFETs are coupled in series with the series coupled N-channel MOSFETs between the supply voltage terminal that is configured to receive a supply voltage V_{ddio} and the ground terminal configured to receive a ground voltage;
 - wherein drains of the second P-channel MOSFET and the first N-channel MOSFET are connected together and to the I/O pad;
 - wherein a gate of the second P-channel MOSFET is biased to $V_{ddio}/2$;
 - wherein a gate of the first N-channel MOSFET is biased to $V_{ddio}/2$;
 - wherein a gate of the first P-channel MOSFET is controlled by the voltage at the first node;
 - wherein a gate of the second N-channel MOSFET is controlled by the voltage at the third node.
4. The IC of claim 3 wherein the level shifter comprises:
 - a first stack of MOSFETs coupled between the supply voltage terminal and the ground terminal;
 - wherein the first stack comprises first and second P-channel MOSFETs coupled in series, and first and second N-channel MOSFETs coupled in series, wherein the series coupled P-channel MOSFETs and the series coupled N-channel MOSFETs of the first stack are coupled in series between the supply voltage terminal and the ground terminal, and wherein the source and drain of the first and second N-channel MOSFETs of the first stack are connected to each other and to the second node.
5. The IC of claim 1 wherein the I/O buffer further comprises a pair of inverters coupled in series between the second and third nodes.

14

6. The IC of claim 1 further comprising:
 - a core circuit configured to generate the data signal and the first control signal in an input voltage domain;
 - wherein the first, second, and input voltage domains are distinct from each other.
7. An integrated circuit (IC) comprising:
 - an input/output (I/O) buffer comprising:
 - an I/O pad;
 - a logic circuit configured to generate a signal based on first and second input signals;
 - a level shifter configured to generate first and second output signals based on the signal from the logic circuit;
 - a control circuit configured to receive the second output signal and the first input signal;
 - an output stage configured to drive the I/O pad, wherein the output stage comprises first and second transistors;
 - wherein the control circuit is configured to activate or deactivate the second transistor based on the second output signal while the first input signal is asserted;
 - wherein the control circuit is configured to deactivate the second transistor while the first input signal is not asserted.
8. The IC of claim 7 wherein:
 - the first and second input signals have input logic levels [LVI,HVI] where LVI defines a voltage for logic low and HVI defines a voltage for logic high;
 - the first output signal has first logic levels [LV1,HV1] where LV1 defines a voltage for logic low and HV1 defines a voltage for logic high;
 - the second output signal has second logic levels [LV2, HV2] where LV2 defines a voltage for logic low and HV2 defines a voltage for logic high;
 - wherein HV1, HV2, and HVI are distinct from each other.
9. The IC of claim 8 wherein:
 - the first input signal is asserted when it is set to HVI;
 - the first input signal is not asserted when it is set to LVI.
10. The IC of claim 7 wherein the output stage comprises:
 - first and second P-channel MOSFETs coupled in series;
 - first and second N-channel MOSFETs coupled in series;
 - wherein the series coupled P-channel MOSFETs are coupled in series with the series coupled N-channel MOSFETs between a supply voltage terminal configured to receive a supply voltage V_{ddio} , and a ground terminal configured to receive a ground voltage;
 - wherein the first P-channel MOSFET is the first transistor, and the second N-channel MOSFET is the second transistor;
 - wherein drains of the second P-channel MOSFET and the first N-channel MOSFET are connected together and to the I/O pad;
 - wherein a gate of the second P-channel MOSFET is biased to $V_{ddio}/2$;
 - wherein a gate of the first N-channel MOSFET is biased to $V_{ddio}/2$.
11. The IC of claim 10 wherein the level shifter comprises:
 - a first stack of MOSFETs comprising:
 - first and second P-channel MOSFETs coupled in series;
 - first and second N-channel MOSFETs coupled in series;
 - wherein the series coupled P-channel MOSFETs and the series coupled N-channel MOSFETs of the first stack are coupled in series between the supply voltage terminal and the ground terminal;

15

wherein the source and drain of the first and second N-channel MOSFETs of the first stack are connected to each other and to a first terminal where the second signal is generated.

12. The IC of claim 7 wherein the logic circuit is configured to receive a third input signal, and wherein the logic circuit is configured to generate the signal based on the first, second and third input signals.

13. The IC of claim 7 further comprising:

a core circuit configured to generate the first and second input signals;

wherein the first input signal comprises an I/O buffer enable signal;

wherein the second input signal comprises a data signal.

14. An integrated circuit (IC) comprising:

an input/output (I/O) buffer comprising:

an I/O pad;

an output stage configured to drive the I/O pad;

a logic circuit configured to generate a binary output signal based on first and second binary input signals;

a level shifter configured to generate first and second binary output signals based on the binary output signal from the logic circuit;

a control circuit configured to receive the first binary input signal and the second binary output signal;

wherein the control circuit is configured to control the output stage based on the first binary input signal and the second binary output signal.

15. The IC of claim 14 wherein the output stage comprises a first and second P-channel MOSFETs coupled in series; a first and second N-channel MOSFETs coupled in series; wherein the series coupled P-channel MOSFETs are coupled in series with the series coupled N-channel MOSFETs between a supply voltage terminal configured to receive a supply voltage V_{ddio} and a ground terminal configured to receive a ground voltage;

wherein drains of the second P-channel MOSFET and the first N-channel MOSFET are connected together and to the I/O pad;

wherein a gate of the second P-channel MOSFET is biased to $V_{ddio}/2$;

wherein a gate of the first N-channel MOSFET is biased to $V_{ddio}/2$.

16. The IC of claim 14 wherein the control circuit comprises first and second invertors coupled in series, and an activation circuit, wherein the first invertor is configured

16

to receive the second binary output signal, wherein the activation circuit is configured to deactivate the second invertor when the first binary input signal is not asserted, and wherein the activation circuit is configured to activate the second invertor when the first binary input signal is asserted.

17. The IC of claim 15 wherein the control circuit comprises an output configured to control the voltage at a gate of the second N-channel MOSFET, wherein the control circuit is configured to activate or deactivate the second N-channel MOSFET based on the second binary output signal while the first binary input signal is asserted, and wherein the control circuit is configured to deactivate the second N-channel MOSFET while the first binary input signal is not asserted.

18. The IC of claim 14 wherein:

the first and second binary input signals have input logic levels [LVI,HVI] where LVI defines a voltage for logic low and HVI defines a voltage for logic high;

the first binary output signal has first logic levels [LV1, HV1] where LV1 defines a voltage for logic low and HV1 defines a voltage for logic high;

the second binary output signal has second logic levels [LV2,HV2] where LV2 defines a voltage for logic low and HV2 defines a voltage for logic high;

wherein HV1, HV2, and HVI are distinct from each other.

19. The IC of claim 14 further comprising:

a core circuit configured to generate the first and second binary input signals;

wherein the first binary input signal comprises an I/O buffer enable signal;

wherein the second binary input signal comprises a data signal.

20. The IC of claim 14 wherein the level shifter comprises:

a first stack of MOSFETs comprising:

first and second P-channel MOSFETs coupled in series;

first and second N-channel MOSFETs coupled in series;

wherein the series coupled P-channel MOSFETs and the series coupled N-channel MOSFETs of the first stack are coupled in series between a supply voltage V_{ddio} terminal and a ground terminal;

wherein the source and drain of the first and second N-channel MOSFETs of the first stack are connected to each other and to a first terminal where the second binary output signal is generated.

* * * * *